

<u>HS96</u>	<u>Description</u>	<u>Base rate</u>	<u>Bound rate</u>	<u>Implementation</u>	<u>Present concession established</u>	<u>Concession first incorporated in a GATT Schedule</u>	<u>Earlier INRs</u>	<u>ODCs</u>
8532	Electrical capacitors, fixed, variable or adjustable (pre-set).							
85321000	-Fixed capacitors designed for use in 50/60 Hz circuits and having a reactive power handling capacity of not less than 0.5 kvar (power capacitors)	0	0	1997	WT/Let			
	-Other fixed capacitors:							
85322100	--Tantalum	0	0	1997	WT/Let			
85322200	--Aluminium electrolytic	0	0	1997	WT/Let			
85322300	--Ceramic dielectric, single layer	0	0	1997	WT/Let			
85322400	--Ceramic dielectric, multilayer	0	0	1997	WT/Let			
85322500	--Dielectric of paper or plastics	0	0	1997	WT/Let			
85322900	--Other fixed capacitors	0	0	1997	WT/Let			
85323000	-Variable or adjustable (pre-set) capacitors	0	0	1997	WT/Let			
85329000	-Parts	0	0	1997	WT/Let			
8533	Electrical resistors (including rheostats and potentiometers), other than heating resistors.							
85331000	-Fixed carbon resistors, composition or film types	0	0	1997	WT/Let			
	-Other fixed resistors:							
85332100	--For a power handling capacity not exceeding 20 W	0	0	1997	WT/Let			
85332900	--Other	0	0	1997	WT/Let			
	-Wirewound variable resistors, including rheostats and potentiometers:							
85333100	--For a power handling capacity not exceeding 20 W	0	0	1997	WT/Let			
85333900	--For a power handling capacity exceeding 20W	0	0	1997	WT/Let			
85334000	-Other variable resistors, including rheostats and potentiometers	0	0	1997	WT/Let			
85339000	-Parts	0	0	1997	WT/Let			
8534	Printed circuits.							

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85340000	-Printed circuits	0	0	1997	WT/Let		
8536	Electrical apparatus for switching or protecting electrical circuits, or for making connections to or in electrical circuits (for example, switches, relays, fuses, surge suppressors, plugs, sockets, lamp-holders, junction boxes), for a voltage not exceeding 1,000 volts.						
85365000	-Other switches						
ex85365000	--Electronic AC switches consisting of optically coupled input and output circuits (Insulated thyristor AC switches)	0	0	1997	WT/Let		
ex85365000	--Electronic switches, including temperature protected electronic switches, consisting of a transistor and a logic chip (chip-on-chip technology) for a voltage not exceeding 1000 volts	0	0	1997	WT/Let		
ex85365000	--Electromechanical snap-action switches for a current not exceeding 11 amps	0	0	1997	WT/Let		
85366900	-Lamp-holders, plugs and sockets:						
	--Other						
ex85366900	---Plugs and sockets for co-axial cables and printed circuits	0	0	1997	WT/Let		
85369010	-Other apparatus						
ex85369010	--Connection and contact elements for wires and cables	0	0	1997	WT/Let		
85369090	-Other						
ex85369090	--Wafer probers	0	0	1997	WT/Let		
ex85369090	--Connection and contact elements of wires and cables	0	0	1997	WT/Let		

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8541	Diodes, transistors and similar semiconductor devices; photosensitive semiconductor devices, including photovoltaic cells whether or not assembled in modules or made up into panels; light emitting diodes; mounted piezo-electric crystals.						
85411000	-Diodes, other than photosensitive or light emitting diodes	0	0	1997	WT/Let		
85412100	-Transistors, other than photosensitive transistors: --With a dissipation rate of less than 1 W	0	0	1995	WT/Let	UR/94	
85412900	--With a dissipation rate of 1W or more	0	0	1995	WT/Let	UR/94	
85413000	-Thyristors, diacs and triacs, other than photosensitive devices	0	0	1995	WT/Let	UR/94	
85414010	-Photosensitive semiconductor devices, including photovoltaic cells whether or not assembled in modules or made up into panels; light emitting diodes	0	0	1995	WT/Let	UR/94	
85414090	---Other	0	0	1995	WT/Let	UR/94	
85415000	-Other semiconductor devices	0	0	1997	WT/Let		
85416000	-Mounted piezo-electric crystals	0	0	1997	WT/Let		
85419000	-Parts	0	0	1997	WT/Let		
8542	Electronic integrated circuits and microassemblies.						
	-Monolithic digital integrated circuits:						
85421200	--Cards incorporating an electronic integrated circuit ("smart" cards)	0	0	1995	WT/Let	UR/94	
85421300	--Metal oxide semiconductors (MOS technology)	0	0	1995	WT/Let	UR/94	
85421400	--Circuits obtained by bipolar technology	0	0	1995	WT/Let	UR/94	

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85421900	--Other including circuits obtained by a combination of bipolar and MOS technologies (BIMOS technology)	0	0	1995	WT/Let		UR/94		
85423000	-Other monolithic integrated circuits	0	0	1995	WT/Let		UR/94		
85424000	-Hybrid integrated circuits	0	0	1997	WT/Let				
85425000	-Electronic microassemblies	0	0	1997	WT/Let				
85429000	-Parts	0	0	1997	WT/Let				
8543	Electrical machines and apparatus, having individual functions, not specified or included elsewhere in this Chapter								
	-Particle accelerators:								
85431100	--Ion implanters for doping semiconductor materials	0	0	1997	WT/Let				
85433000	-Machines and apparatus for electroplating, electrolysis or electrophoresis								
ex85433000	--Apparatus for wet etching, developing, stripping or cleaning semiconductor wafers and flat panel displays	0	0	1997	WT/Let				
	-Other machines and apparatus:								
85438100	--Proximity cards and tags	0	0	1997	WT/Let				
85438900	--Other								
ex85438900	---Plasmaspitter and such devices	0	0	1997	WT/Let				
ex85438900	---Electrical machines with translation or dictionary functions	0	0	1997	WT/Let				
85439000	-Parts								
ex85439000	--Parts of apparatus for wet etching, developing, stripping or cleaning semiconductor wafers and flat panel displays	0	0	1997	WT/Let				
ex85439000	--Parts of ion implanters for doping semiconductor materials	0	0	1997	WT/Let				

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8544	Insulated (including enamelled or anodised) wire, cable (including coaxial cable) and other insulated electric conductors, whether or not fitted with connectors; optical fibre cables, made up of individually sheathed fibres, whether or not assembled with electric conductors or fitted with connectors.							
85444100	-Other electric conductors, for a voltage not exceeding 80 V.							
ex85444100	--Fitted with connectors	0	0	1997	WT/Let			
85444900	---Other electric conductors, for a voltage not exceeding 80 V, fitted with connectors, of a kind used for telecommunications							
ex85444900	--Other	0	0	1997	WT/Let			
85445100	---Other electric conductors, for a voltage exceeding 80 V but not exceeding 1,000 V							
ex85445100	--Fitted with connectors	0	0	1997	WT/Let			
85447000	---Other electric conductors, for a voltage exceeding 80 V but not exceeding 1,000 V, fitted with connectors, of a kind used for telecommunications							
9009	-Optical fibre cables	0	0	1997	WT/Let			
	Photo-copying apparatus incorporating an optical system or of the contact type and thermocopying apparatus.							
	-Electrostatic photo-copying apparatus:							

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90091100	--Operating by reproducing the original image directly onto the copy (direct process)	0	0	1997	WT/Let				
	-Other photo-copying apparatus:								
90092100	--Incorporating an optical system	0	0	1997	WT/Let				
90099000	-Parts and accessories	0	0	1995	WT/Let			UR/94	
9010	Apparatus and equipment for photographic (including cinematographic) laboratories (including apparatus for the projection or drawing of circuit patterns on sensitised semiconductor materials), not specified or included elsewhere in this Chapter; negatoscopes; projection screens.								
	-Apparatus for the projection or drawing of circuit patterns on sensitised semiconductor materials:								
90104100	--Direct write-on-wafer apparatus	0	0	1997	WT/Let				
90104200	--Step and repeat aligners	0	0	1997	WT/Let				
90104900	--Other	0	0	1997	WT/Let				
90109000	-Parts and accessories								
ex90109000	--Parts and accessories of the apparatus of Headings No 9010 4100 to 9010 4900	0	0	1997	WT/Let				
9011	Compound optical microscopes, including those for photomicrography, cinemicrophotography or microprojection								
90111000	-Stereoscopic microscopes								
ex90111000	--Optical stereoscopic microscopes fitted with equipment specifically designed for the handling and transport of semiconductor wafers or reticles	0	0	1997	WT/Let				

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90112000	-Other microscopes, for photomicrography, cinephotomicrography or microprojection							
ex90112000	--Photomicrographic microscopes fitted with equipment specifically designed for the handling and transport of semiconductor wafers or reticles	0	0	1997	WT/Let			
90119000	-Parts and accessories							
ex90119000	--Parts and accessories of optical stereoscopic microscopes fitted with equipment specifically designed for the handling and transport of semiconductor wafers or reticles	0	0	1997	WT/Let			
ex90119000	--Parts and accessories of photomicrographic microscopes fitted with equipment specifically designed for the handling and transport of semiconductor wafers or reticles	0	0	1997	WT/Let			
9012	Microscopes other than optical microscopes; diffraction apparatus							
90121000	-Microscopes than optical microscopes and diffraction apparatus							
ex90121000	--Electron beam microscopes fitted with equipment specifically designed for the handling and transport of semiconductor wafers or reticles	0	0	1997	WT/Let			
90129000	-Parts and accessories							
ex90129000	--Parts and accessories electron beam microscopes fitted with equipment specifically designed for the handling and transport of semiconductor wafers or reticles	0	0	1997	WT/Let			

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9017	Drawing, marking-out or mathematical calculating instruments (for example, drafting machines, pantographs, protractors, drawing sets, slide rules, disc calculators); instruments for measuring length, for use in the hand (for example, measuring rods and tapes, micrometers, callipers), not specified or included elsewhere in this Chapter						
90171000	-Drafting tables and machines, whether or not automatic						
ex90171000	--Plotters whether input or output units of HS heading No. 8471 or drawing or drafting machines of HS heading No. 9017	0	0	1997	WT/Let		
90172000	-Other drawing, marking-out or mathematical calculating instruments						
ex90172000	--Pattern generating apparatus of a kind used for producing masks or reticles from photoresist coated substrates	0	0	1997	WT/Let		
ex90172000	--Plotters whether input or output units of HS heading No. 8471 or drawing or drafting machines of HS heading No. 9017	0	0	1997	WT/Let		
90179000	-Parts and accessories						
ex90179000	--Parts and accessories for pattern generating apparatus of a kind used for producing masks or reticles from photoresist coated substrates	0	0	1997	WT/Let		
ex90179000	--Parts of such pattern generating apparatus	0	0	1997	WT/Let		

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9026	Instruments and apparatus for measuring or checking the flow level, pressure or other variables of liquids or gases (for example, flow meters, level gauges, manometers, heat meters), excluding instruments and apparatus of heading No. 90.14, 90.15, 90.28 or 90.32.	0	0	1995	WT/Let	UR/94	
90261000	-For measuring or checking the flow or level of liquids	0	0	1995	WT/Let	UR/94	
90262000	-For measuring or checking pressure	0	0	1995	WT/Let	UR/94	
90268000	-Other instruments or apparatus	0	0	1995	WT/Let	UR/94	
90269000	-Parts and accessories	0	0	1995	WT/Let	UR/94	
9027	Instruments and apparatus for physical or chemical analysis (for example, polarimeters, refractometers, spectrometers, gas or smoke analysis apparatus); instruments and apparatus for measuring or checking viscosity, porosity, expansion, surface tension or the like; instruments and apparatus for measuring or checking quantities of heat, sound or light (including exposure meters); microtomes.						
90272000	-Chromatographs and electrophoresis instruments	0	0	1995	WT/Let	UR/94	
90273000	-Spectrometers, spectrophotometers and spectrographs using optical radiations (UV, visible, IR)	0	0	1995	WT/Let	UR/94	
90275000	-Other instruments and apparatus using optical radiations (UV, visible, IR)	0	0	1995	WT/Let	UR/94	
90278000	-Other instruments and apparatus	0	0	1995	WT/Let	UR/94	
90279000	-Microtomes; parts and accessories	0	0	1995	WT/Let	UR/94	

